



### **SUMMER TRAINING PROGRAM 2025**

# FABRICATION & CHARACTERIZATION OF SEMICONDUCTING DEVICES FOR SENSING APPLICATIONS

Research-driven and Industry-oriented Curriculum in Electronics and Computing

### **COURSE OBJECTIVE**

The objective of this course is to provide students with comprehensive knowledge and hands-on experience in the design, fabrication, and characterization of semiconducting devices tailored for sensing applications. The course aims to equip learners with an understanding of semiconductor materials, micro/nanofabrication techniques, and analytical methods used to evaluate device performance, with a focus on their integration into chemical, biological, and environmental sensors.

### **COURSE OUTCOMES**



Understand Semiconductor Materials and Device Physics: Students will be able to explain the fundamental properties of semiconductor materials and their relevance in designing sensing devices.



Apply Fabrication Techniques for Sensor

Development: Students will gain practical skills in micro/nanofabrication processes such as photolithography, thin-film deposition, and etching for constructing semiconducting sensors.



Characterize and Evaluate Sensor Performance: Students will be able to perform electrical and structural characterization of semiconducting devices and interpret data to assess sensing efficiency, sensitivity, and reliability. **COURSE DURATION:** 

**COURSE FEE:** 

40 + Project (20)

• KIIT Affiliation: Rs. 4000/-\*

• Other Affiliation: Rs 5000/-\*

\*(Exclusive of Fooding & Lodging)

**TEACHING LEARNING MODE:** 

**COURSE INSTRUCTORS:** 

**Hybrid Mode** 

• Dr.(Prof.). U. P. Singh

• Dr. Arindam Basak

**COURSE EVALUATION:** 

**COURSE CERTIFICATE:** 

**Continuous Evaluation** 

After successful completion

of the course.



### **MODULE 1**

#### **SYNTHESIS AND FABRICATION TOOLS:**

- → Thermal and Co-evaporation
- → DC/RF sputtering
- Chemical Bath Deposition
- Dip Coating
- → RTPs

#### **SIMULATION TOOL:**

→ SCAPS 1D introduction

# **MODULE 2**

#### **SPECTROSCOPIC ANALYSIS:**

→ UV-VIS-NIR Spectrophotometry

#### **SIMULATION TOOL:**

 Device parameter variation and result optimization using SCAPS ID simulation

# **MODULE 3**

#### **STRUCTURAL ANALYSIS:**

- > X-Ray Diffraction (XRD)
- → EDXRF

# **MODULE 4**

#### **ELECTRICAL CHARACTERIZATION:**

- → Hall Effect
- → I-V and C-V measurement
- Device parameter measurement and validation with SCAPS ID



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